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Applied Physics Letters. Vol: Page: Publishers; Submicron, vacuum ultraviolet contact lithography with an F 2 excimer laser

<http://scitation.aip.org/content/aip/journal/apl/44/1/10.1063/1.94589>

Title: Fabrication of high quality sub-micron Au gratings over large areas with pulsed laser interference lithography for SPR sensors

<http://arxiv.org/abs/1302.2660?context=physics>

Abstract In order to study the feasibility of submicron lithography using second-harmonic light (SHL) at wavelength of 255.3 nm of copper vapor laser (CVL), a 1:1

<http://adsabs.harvard.edu/abs/1997SPIE.3051..967H>

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Abstract We present results of our evaluation of the X-ray lithographic technique for replication of submicron patterns generated by electron beam.

<http://adsabs.harvard.edu/abs/1976SPIE...80..100W>

Femtosecond laser lithography technique for submicron T-gate fabrication on positive photoresist. Technical Institute of Physics and Chemistry,

<http://opticalengineering.spiedigitallibrary.org/article.aspx?articleid=1183638>

Fabrication of submicron structures in nanoparticle/polymer composite by holographic lithography and reactive ion etching A. Ping Zhang, Sailing He, Kyoung Tae Kim

http://physics.anu.edu.au/get_pdf.php?PubID=U9912193XPUB211

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This monograph details the physics behind the methods of generating submicron forms for electron beam, ion beam, optical, and X-ray lithography.

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The Japan Society of Applied Physics Study of Hydrogen Vacuum-Ultraviolet Light Sources for Submicron Lithography Kazuhiro Kudo, Takashi Iwabuchi 1, Katsuhiko

<http://iopscience.iop.org/1347-4065/29/11R/2572/>

A soft-imprint technique for submicron structure fabrication via in situ polymerization Nanoimprint Lithography Using Novolak-Type Photoresist and Soft Mold at

<http://m.iopscience.iop.org/0957-4484/15/1/026>

Institute of general physics of USSR Academy of Sciences, Introduction Production of high performance VLSI's requires effective methods of submicron lithography.

<http://www.sciencedirect.com/science/article/pii/0167931785900449>

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<http://www.amazon.es/Physics-Submicron-Semiconductor-Devices-Science/dp/0306429861>

X ray lithography was studied, using laser produced plasma as a source. A single target shot of a frequency tripled Nd:glass laser ($\lambda = 0.35 \mu\text{m}$, 35 J in 1 ns

<http://scitation.aip.org/content/aip/journal/apl/43/7/10.1063/1.94535>

Jun 01, 2005 Physics > Atomic Physics. Title: Two-dimensional atomic lithography by sub-micron focusing of atomic beams. Authors: W. Williams, M. Saffman

<http://arxiv.org/abs/physics/0506022>

This book is devoted to the physics of electron-beam, ion-beam, optical, and x-ray lithography. The need for this book results from the following considerations.

<http://www.bokus.com/bok/9780306435782/the-physics-of-submicron-lithography/>

Recent developments in electron beam lithography S. Radelaar Center for Submicron Technology, Faculty of Applied Physics Lorentzweg 1, 2628 CJ Delft, The Netherlands

http://proceedings.spiedigitallibrary.org/data/Conferences/SPIEP/65761/0804_3.pdf

X-Ray Lithography and Microscopy for Submicron Structures /21 (Boris W. Batterman, director of the School of Applied and Engineering Physics,

<http://ecommons.library.cornell.edu/handle/1813/2308>

Details the physics behind the methods of generating submicron forms for electron beam, ion beam, optical, and X-ray lithography. This monograph discusses topics at

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Central European Journal of Physics The new method of fabrication of submicron structures by optical lithography with mask shifting and mask rotation Research Article

[http://www.degruyter.com/dg/viewarticle.fullcontentlink:pdfeventlink/\\$002fj\\$002fphys.2013.11.issue-2\\$002fs11534-012-0166-0\\$002fs11534-012-0166-0.pdf?t:ac=j\\$002fphys.2013.11.issue-2\\$002fs11534-012-0166-0\\$002fs11534-012-0166-0.xml](http://www.degruyter.com/dg/viewarticle.fullcontentlink:pdfeventlink/$002fj$002fphys.2013.11.issue-2$002fs11534-012-0166-0$002fs11534-012-0166-0.pdf?t:ac=j$002fphys.2013.11.issue-2$002fs11534-012-0166-0$002fs11534-012-0166-0.xml)

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